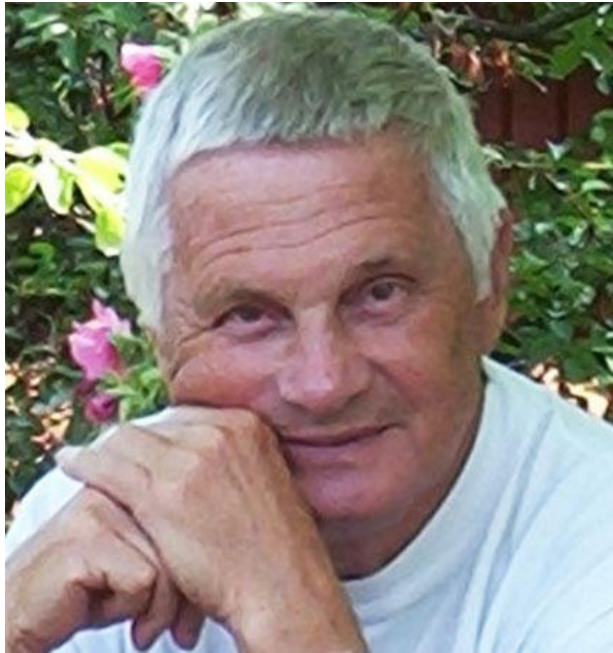


Homage to Boris Dolgoshein (1930-2010)



Chasing the
Ideal LLL Detector:

Large, UV Sensitive
SiPMs with very high
PDE & extremely low
X-talk

Razmik Mirzoyan

Max-Planck-Institute for Physics, Munich, Germany

Homage to Boris Dolgoshein



- Professor, head of the particle-physics department in MEPHI
- Inventor of streamer chamber (1962)
- Developer and pioneer of Transition Radiation Detector (TRD)
- Since 1993 developing a new photon detector which he gave the name Silicon Photo-Multiplier (SiPM).

2nd November 2011,
Light-11, Rinberg,
Germany

R. Mirzoyan: Dream of Boris-
Large SiPMs with maximum PDE
and almost no X-talk

Homage to Boris Dolgoshein



- 1st in the world large-scale SiPM application in Hadron Calorimeter prototype ($\sim 10^4$ SiPM channels)
- In the beginning collaborating with DESY and then with the Max-Planck Institute for Physics in Munich on SiPM
- Developing UV sensitive SiPM with extremely low X-talk and very high PDE for the MAGIC and EUSO experiments, 2002-2010

Homage to Boris Dolgoshein



Boris at „Medical Imaging-2010“ in Stockholm, June 2010

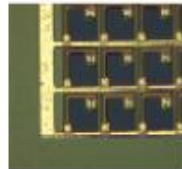
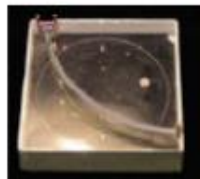
ILC: Potential Consumer of $(5-200) \times 10^6$ SiPMs

- Scintillation Calorimetry- for instance a SciTile Imagine Hadron Calorimeter for ILC (CALICE Collaboration), sci tile size: a few cm
- Typical threshold is $\sim 5-7$ phe

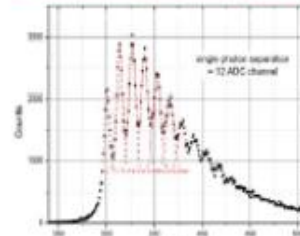


SiPM tile fibre system

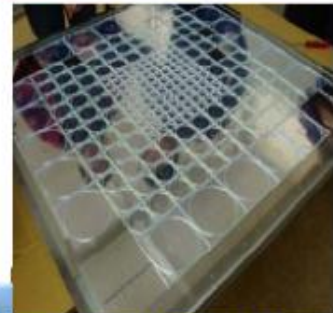
- SiPM developed by MEPhI/PUSAR
 - Gain $\sim 10^6$, bias ~ 50 V, size 1 mm^2 , 1156 pixels
 - Eff (green) $\sim 15\%$, quenching R $\sim 1 - 10 \text{ M}\Omega$
- SiPM tile fibre system integration: ITEP
 - $3 \times 3 \times 0.5 \text{ cm}^3$ tiles from UNIPLAST, Russia
 - WLS fibre Kuraray Y11(300) 1mm
 - Matted edges, 2% light xtalk per edge
 - Faces covered with EM mirror foil



A big 8000 channel HCAL prototype with tail catcher is constructed by CALICE (DESY, ITEP, LAL, MEPhI, NIU, Prague, UK) for analogue and semidigital modes



SiPM&FE signals in calibration mode



One plane with SiPMs and WLS fibers installed into 3×3 , 6×6 and $12 \times 12 \text{ cm}^2$ 0.5 cm thick tiles

CERN test beam, 2006



LAL 18 ch. SiPM FE chip

B. Dolgoshein, SiPM review



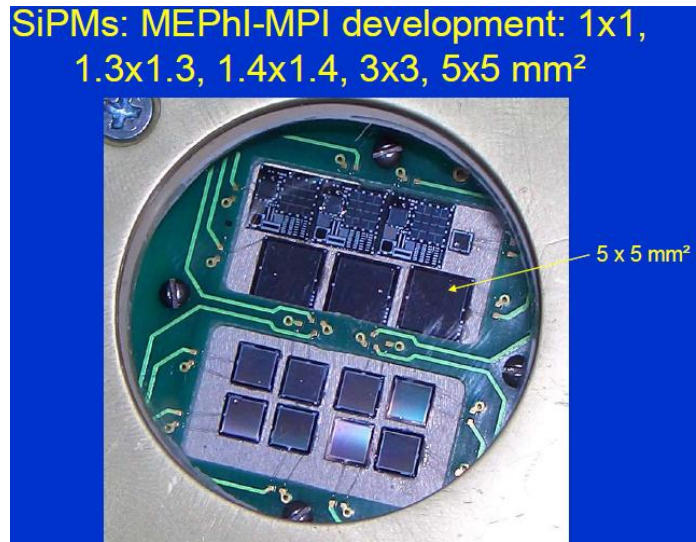
SiPMs for calorimetry

Felix Siefkow PD/07 June 17, 2007 13

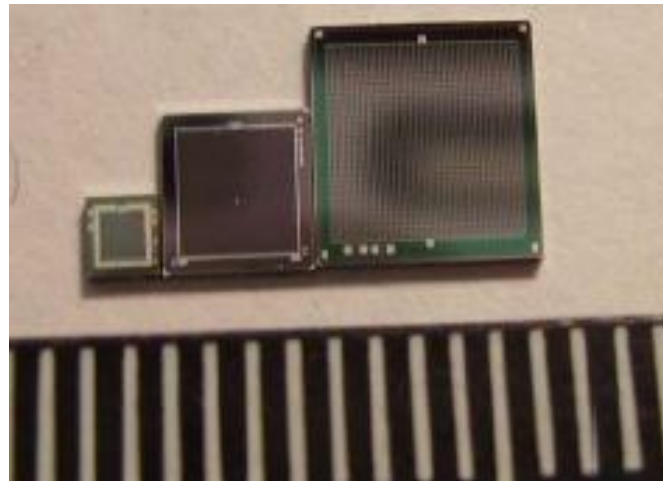
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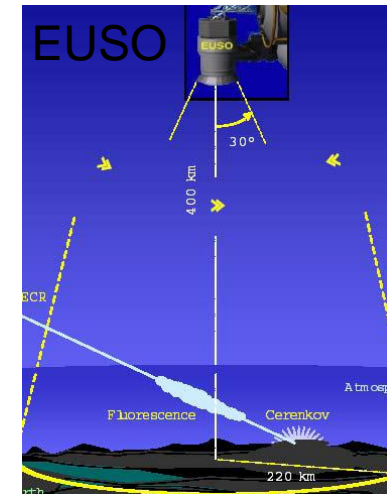


5 patents on SiPM applied in many countries worldwide



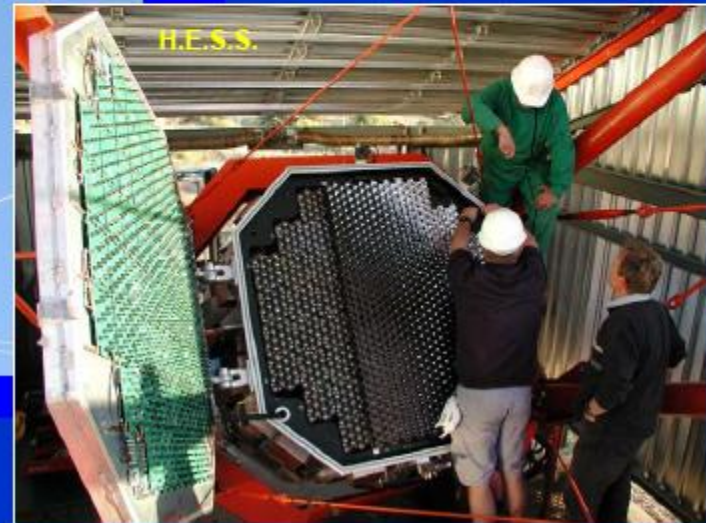
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The Imaging Air Cherenkov γ -ray Telescopes employ cameras of 1-3 m in \varnothing , covered by closely packed 1000-2000 PMTs

Photograph of the 576-pixel imaging camera of MAGIC-I. In the central part one can see the 396 high resolution pixels of 0.10° size. Those are surrounded by 180 pixels of 0.20° .

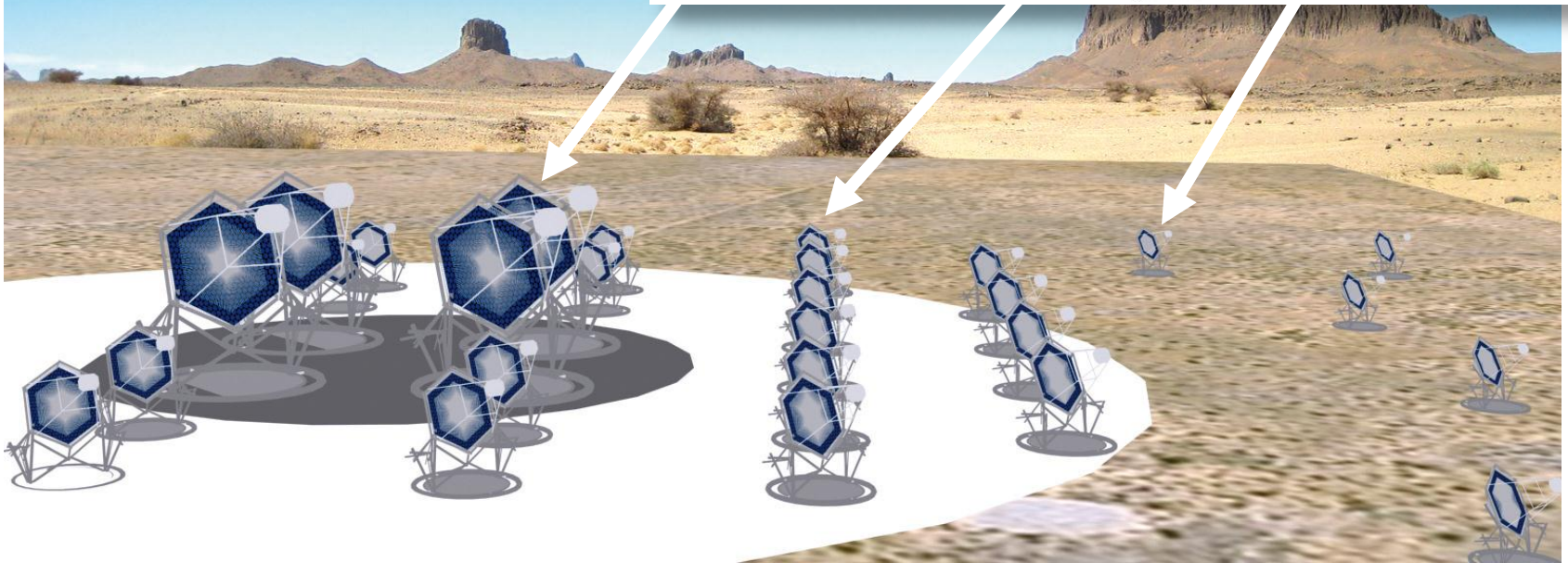
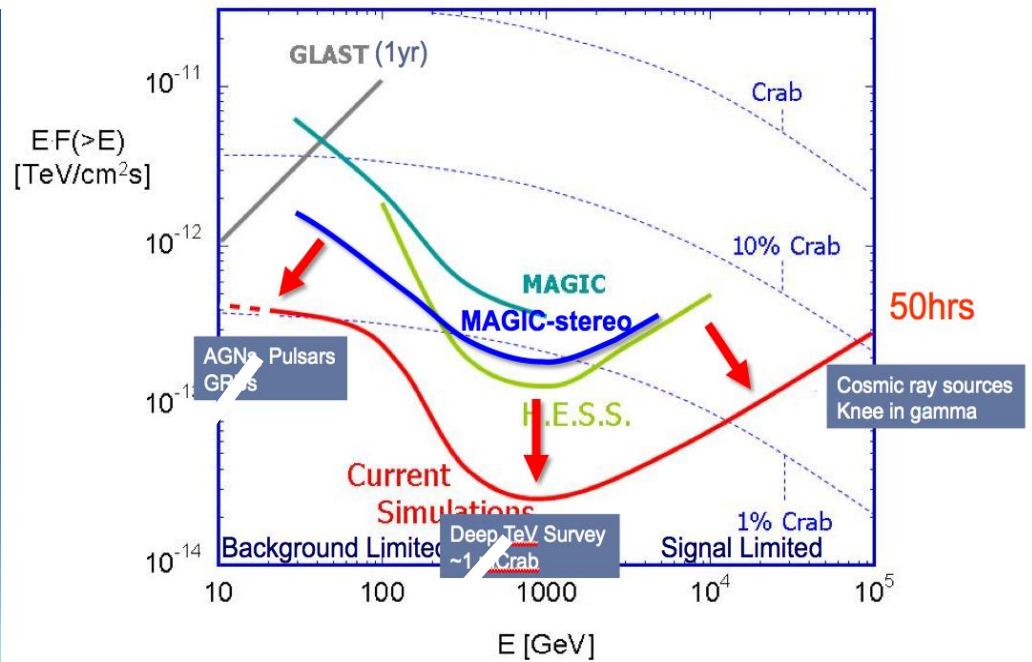


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CTA

~840 scientists Europe,
USA and Japan plan to
build ~100 telescopes
of 3 sizes



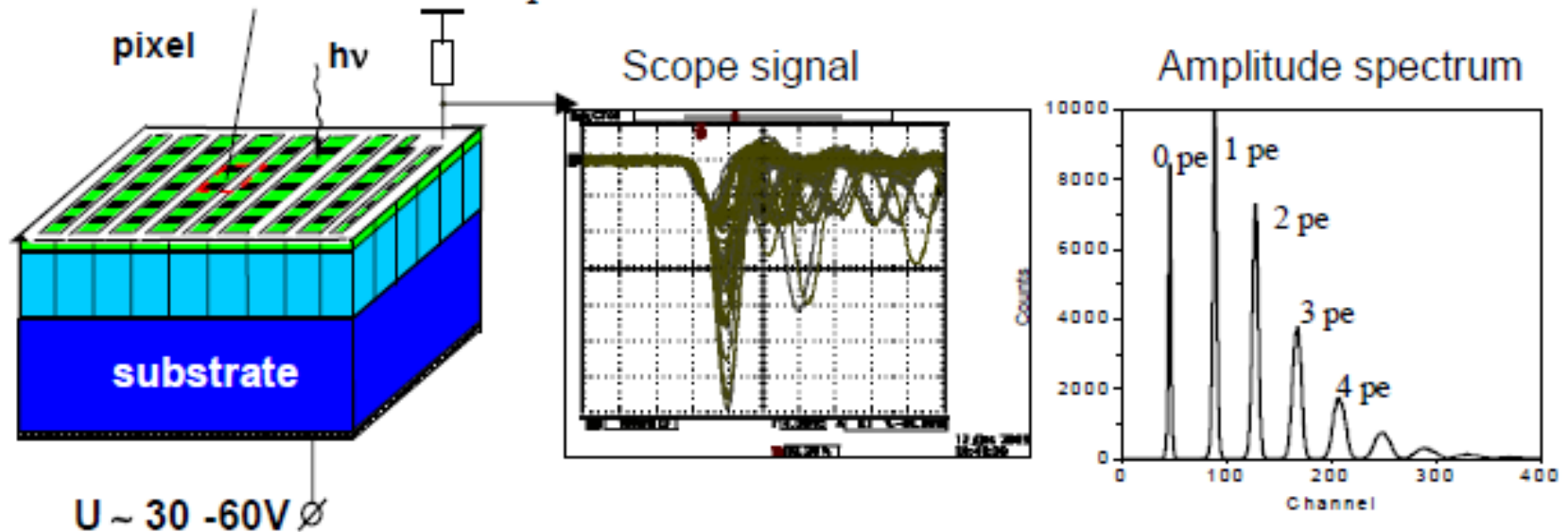
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Silicon Photomultiplier (SiPM)

The novel type of photon detector

Multipixel device with common readout



SiPM - main features:

- Each pixel – reverse biased above breakdown p-n-junction operated in selfquenching Geiger mode
- Sensitivity to single photons
- Pixel gain $\sim 10^6 - 10^7$
- Pixels number: $\sim 100 - 10000/\text{mm}^2$
- Pixel recovery time $R_{\text{pixel}} * C_{\text{pixel}} \sim 30\text{ns} \div 1 \mu\text{s}$

Pixel signal - 0 or 1

But SiPM is analogue device

SiPM Essentials

- Photon Detection Efficiency (PDE):

$$\text{PDE}(\lambda) = \text{QE}_{\text{internal}} \times T(\lambda) \times A_{\text{active area}} \times G_{\text{geiger-eff.}}(\lambda)$$

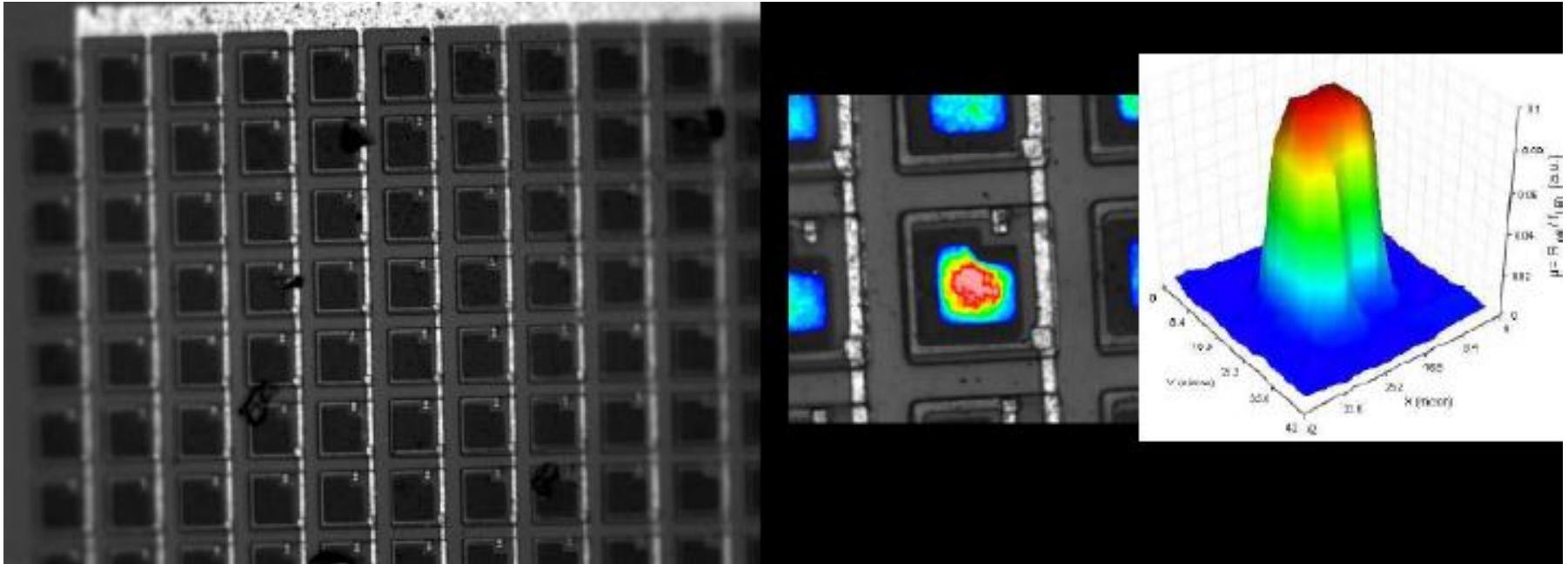
$\text{QE}_{\text{internal}}$: essentially 100 %

$T(\lambda)$: strongly varies with λ , could reach 80-90 %

$A_{\text{active area}}$: some number between 20-80 %

$G_{\text{geiger-eff.}}(\lambda)$: strong function of applied $\Delta U/U$, for $\Delta U/U \geq 12-15$ % could become ≥ 95 %

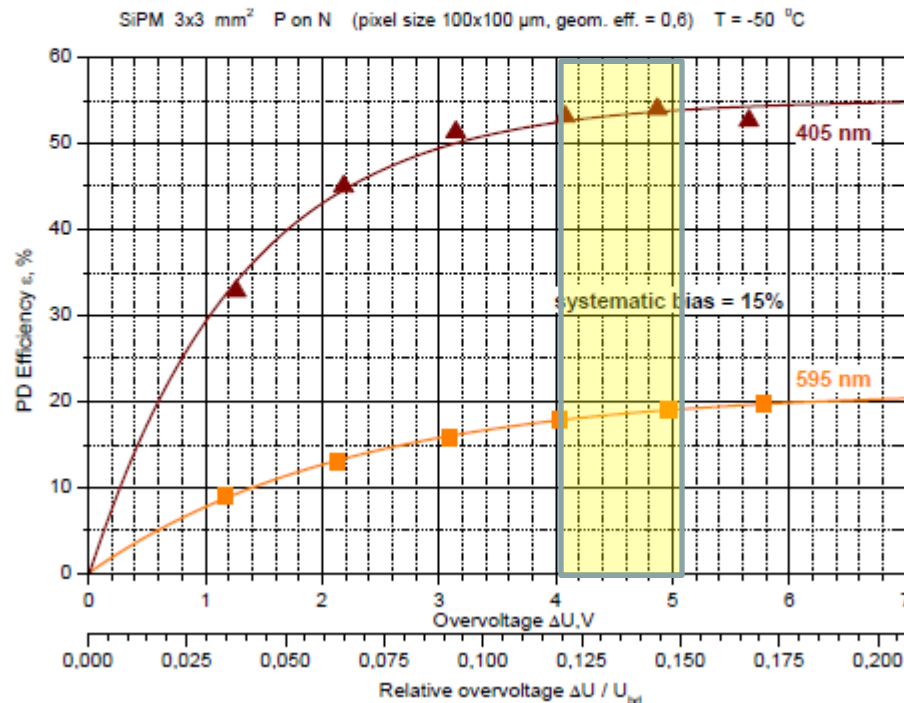
Sensitive area of a cell $A_{\text{active area}}$



Well-optimised SiPM cell topology can provide sensitive area as high as ~80 %. Efficiency losses are due to power lines, polysilicon resistor, trenches and implantation profile.

Geiger Efficiency $G_{\text{geiger-eff.}}(\lambda)$

High Geiger efficiency can be achieved for high
Over-voltage $\Delta U/U$:
Relative overvoltage $\Delta U/U \approx 12 - 15 \%$



Reflectivity of Si

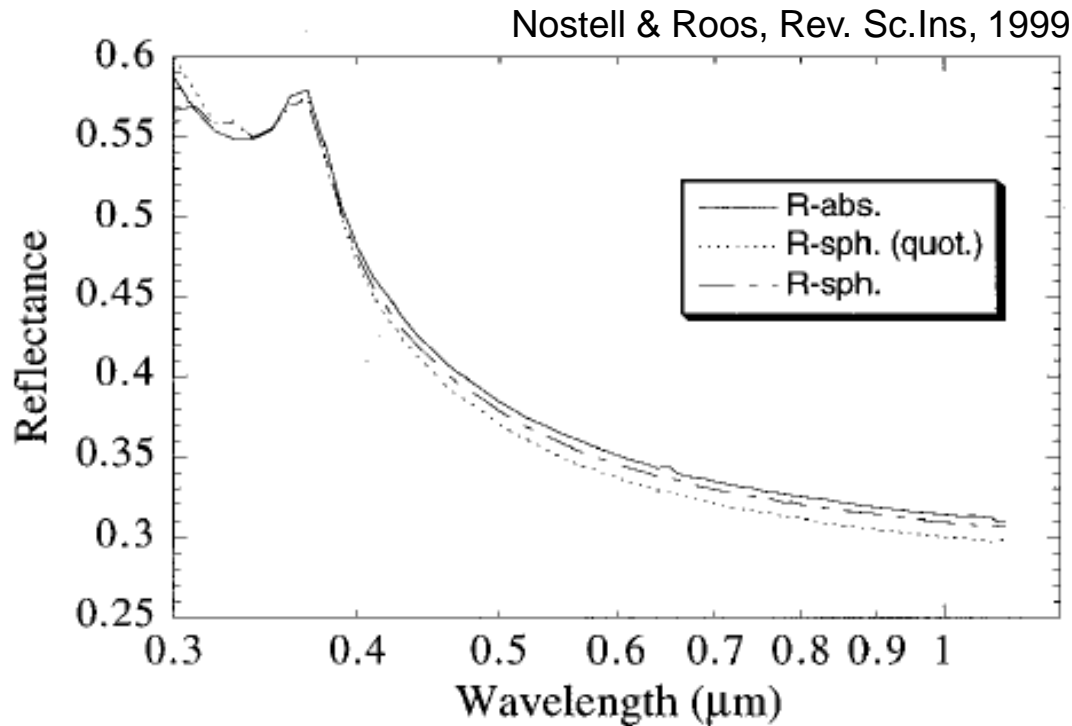


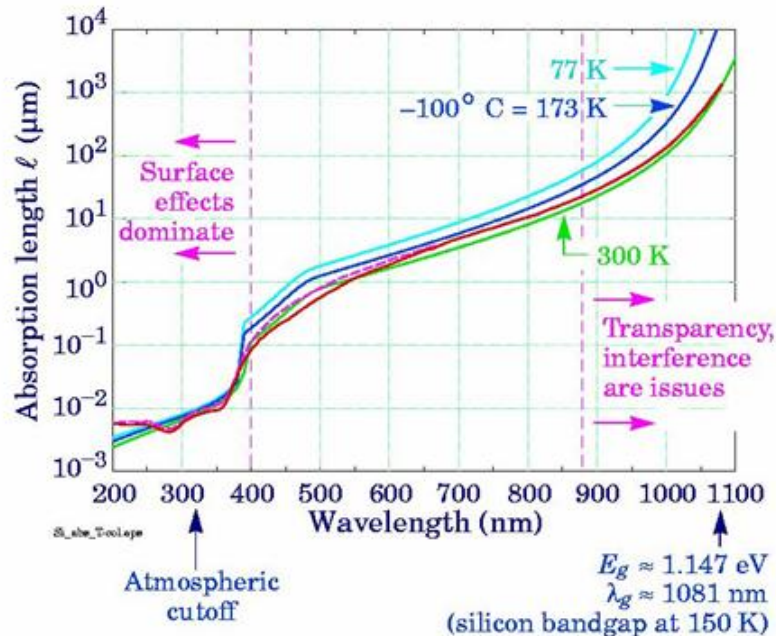
FIG. 19. Near normal reflectance spectra in the wavelength range 0.3–1.1 μm of silicon measured in the absolute spectrophotometer and the reflectance sphere. The reflectance sphere spectra consist of a corrected spectrum, R-sph, and the direct ratio between sample and reference signals, R-sph (quot.).

- Reflectivity of Si varies in the range of ~ 60 – 31 % for the wavelength range 300 – 1000 nm at normal incidence.
- It is obvious that one needs to apply anti-reflective coatings for improving the light Transmission
- Proper choice of the window coating can provide efficiency $\geq 80\text{-}90\%$

Reminder: light absorption in Si

Beaune99: Depleted CCD—5
Don Groom 1999 June 24

This is the most important transparency I will show!



For the long wavelength end, temperature is important

Astronomical CCD's operate near -100°C to achieve noise-limited performance

Red curve is empirical; other curves are calculated from phenomenological fits by Rajkanan *et al.*

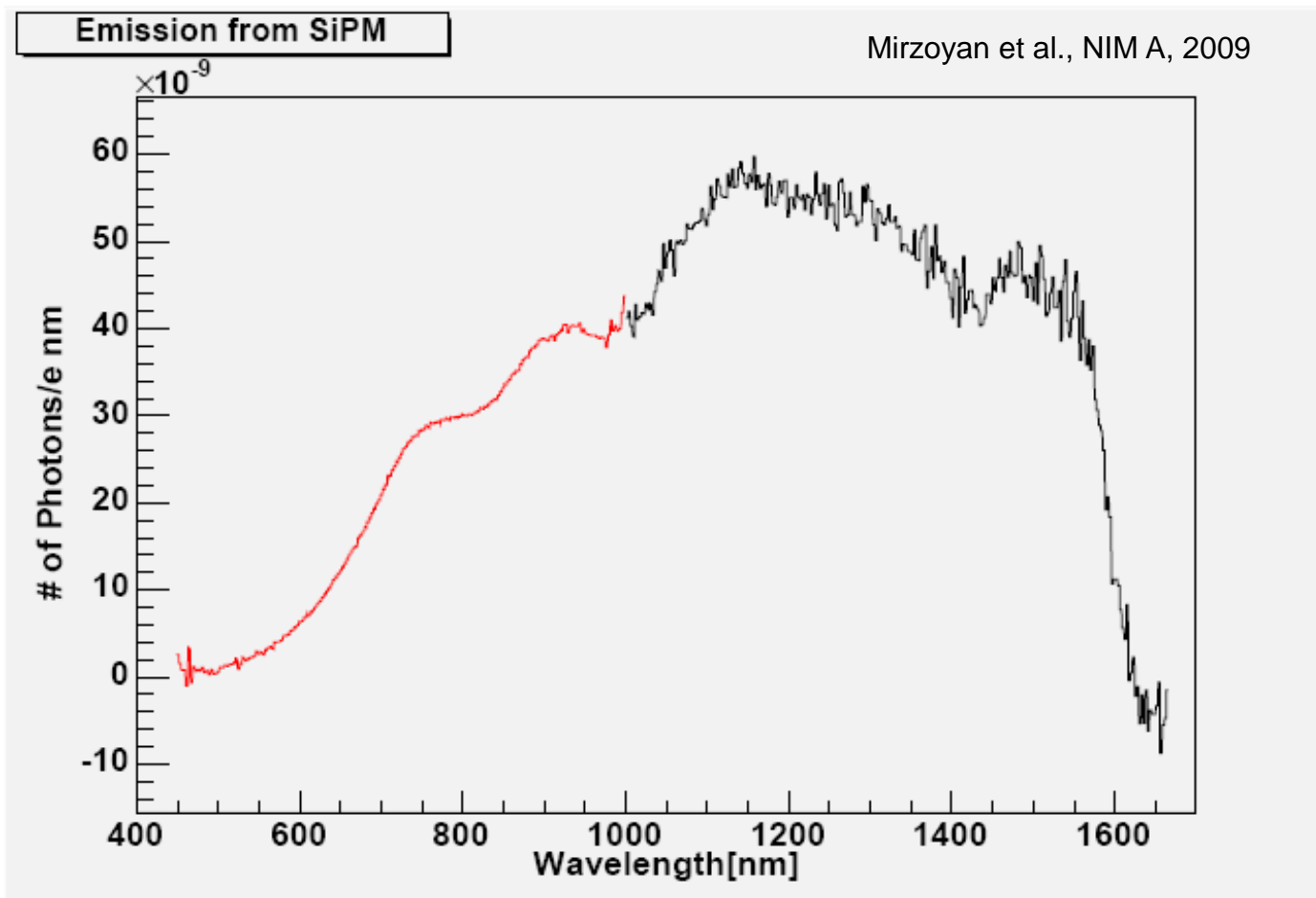
- While light of wavelength 1000nm can penetrate $\sim 100\ \mu\text{m}$ deep into Si, light of 300 nm wavelength can penetrate only 5-7 nm!

- It is a major challenge to collect produced charge carriers from the very surface of the sensor, providing blue – near UV sensitivity

Why the light emission from Si avalanches is important

- First observation of the light emission from reversed-biased Si p-n junction in 1955 (Newman)
- Revived interest about the effect in recent years because of:
- Cross-talk in SiPMs (GAPD, MPPC, micro-channel APD,...) spoils the amplitude resolution
- The light emission is proportional to the number of e- in the avalanche. This puts a limit to the maximum gain under which one can operate the SiPMs
- If no measures are taken against the cross-talk, then the F-factor is worse than in classical PMTs
- As a consequence one encounters major problems in self-trigger schemes when measuring very low light level signals

Light emission spectrum from Si



The largest error is $\leq 19.7\%$ for the „worst“ wavelength range < 600 nm

The PDE and the large cell size

- For max. PDE one needs 1) a large cell size and 2) to operate the SiPM @ high Geiger efficiency
- For this one needs to apply a high over-voltage $\Delta U/U$, which means operating them under very high gain.
- Light emission in Si avalanches is \sim to the number of e^- in the discharge. A high gain means a very high-level of X-talk
- X-talk can become so intense as to simply prohibit the functionality of the sensors.
- This is becoming especially important for large cell area SiPMs.
A $100\mu\text{m} \times 100\mu\text{m}$ size cell has 16-times larger area and capacitance C than a $25\mu\text{m} \times 25\mu\text{m}$ cell. Correspondingly it has 16-times higher gain: $Q = C \times \Delta U$. \rightarrow 16-times higher light emission \rightarrow 16-times higher X-talk
- The X-talk in SiPM is one of the main problems limiting the PDE

Cross-Talk: X-talk

P. Buzhan, B. Dolgoshein, et al., 2009

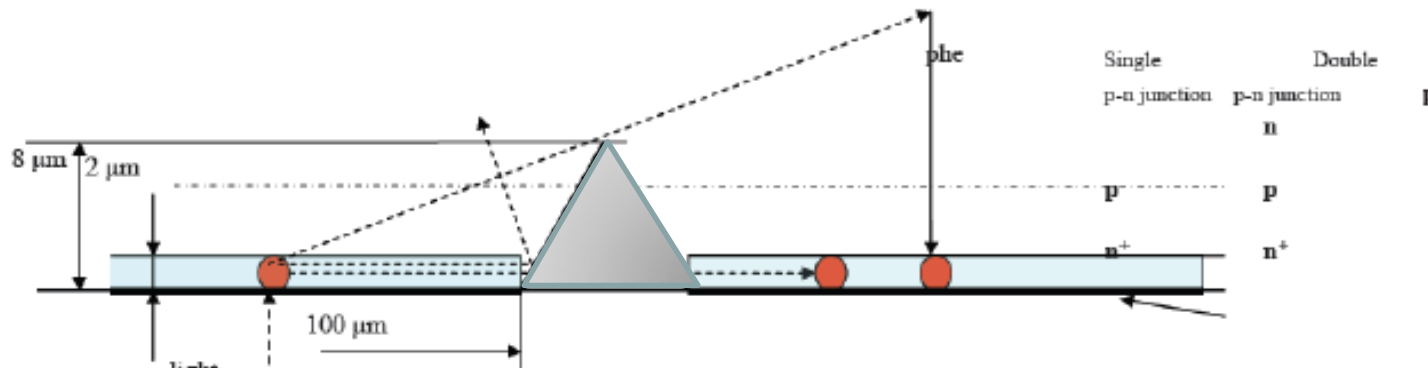
X-talk has (at least) 2 components:

FIRST: phe's are induced in high electric field depletion region of neighbouring pixels

→ this mechanism is very fast: $\sim 1\text{ns}$ (prompt OC)

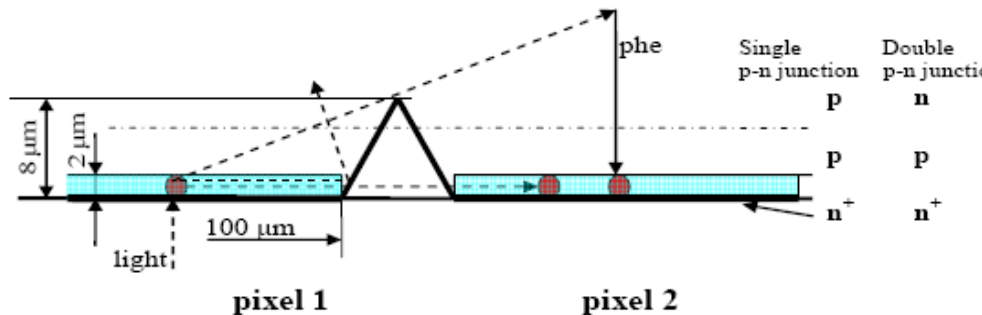
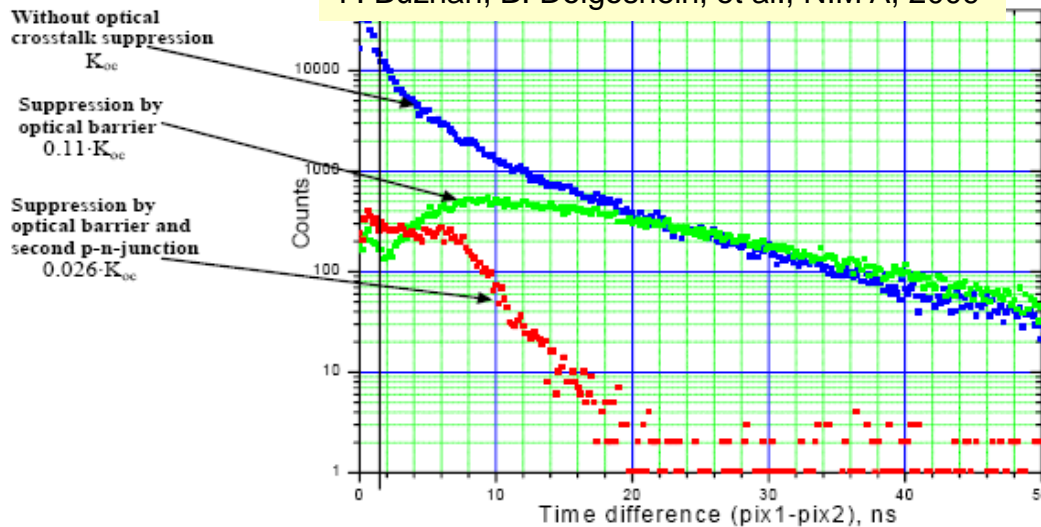
SECOND: The same in undepleted region and then the diffusion (or drift) to high electric field Geiger region of neighbouring pixels

→ this process is delayed: later than 1ns



Optical Crosstalk studies

P. Buzhan, B. Dolgoshein, et al., NIM A, 2009



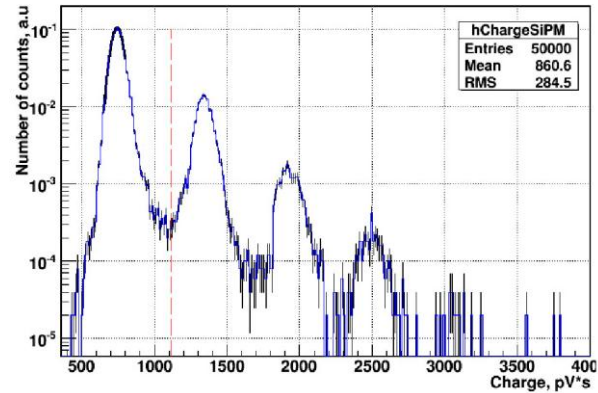
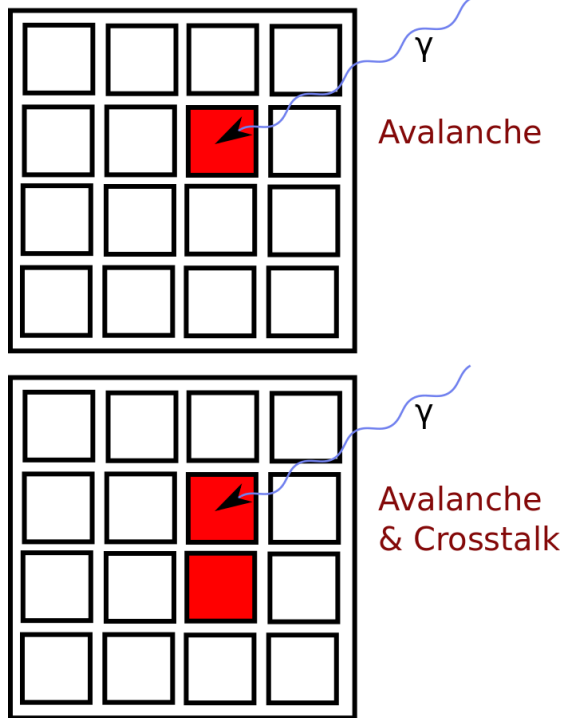
Optical crosstalk between two separate pixels

- Only much later on we, people working next to Boris, could (again) fully appreciate the deep insight and vision of SiPM by Boris.
- He understood very early that only strong suppression of the X-talk can allow one to operate them at full efficiency.
- ~6 years ago during 2 years different recipes were tried in 4-production batches for suppressing the X-talk
- That was successful

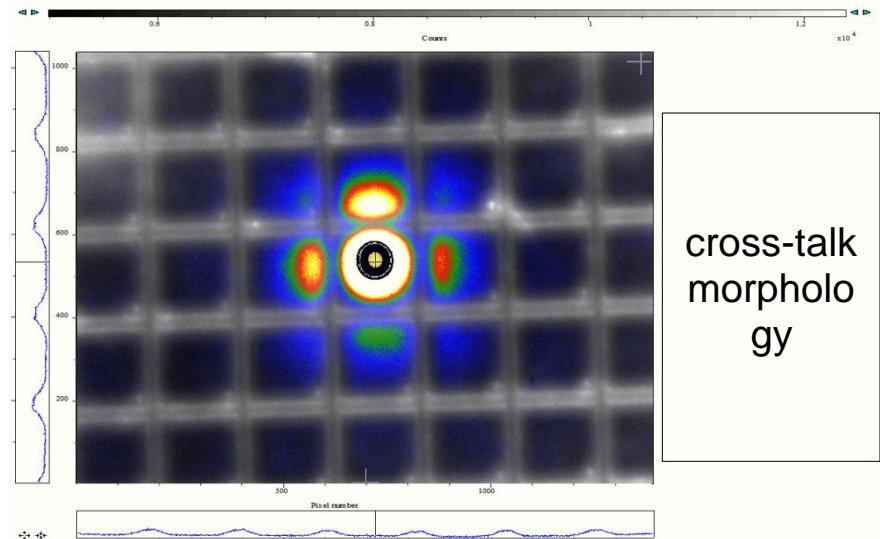
X-talk in SiPM

SiPM cross-talk

SiPM Illustration

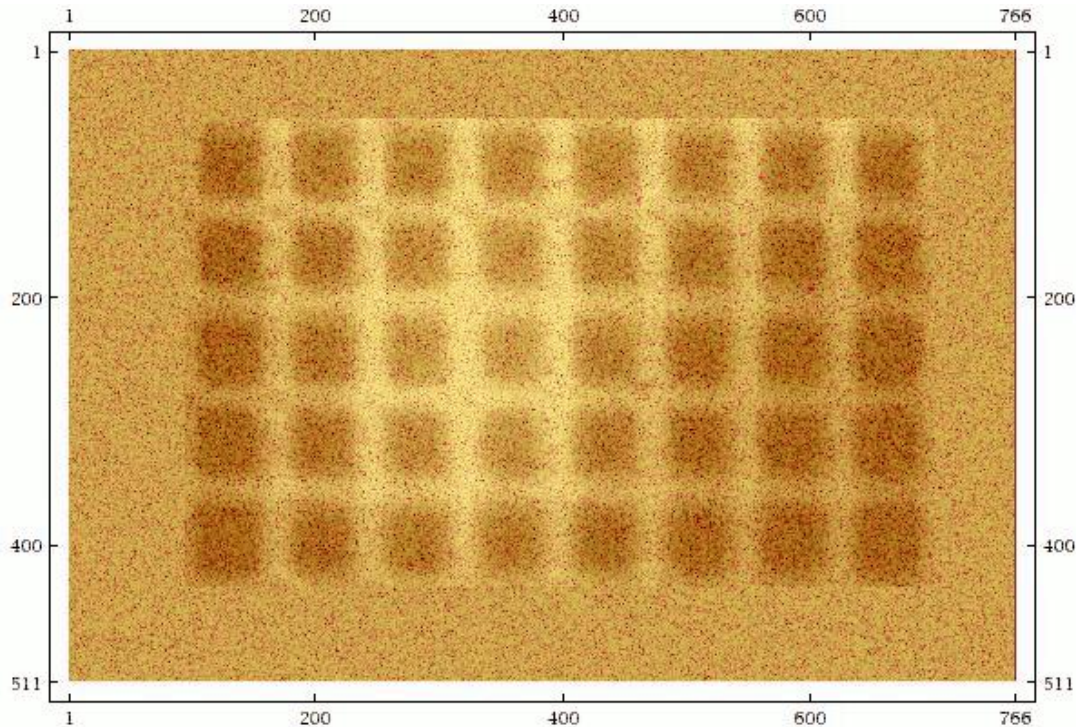


Charge spectrum



cross-talk morphology

Time Resolved imaging of cross-talk

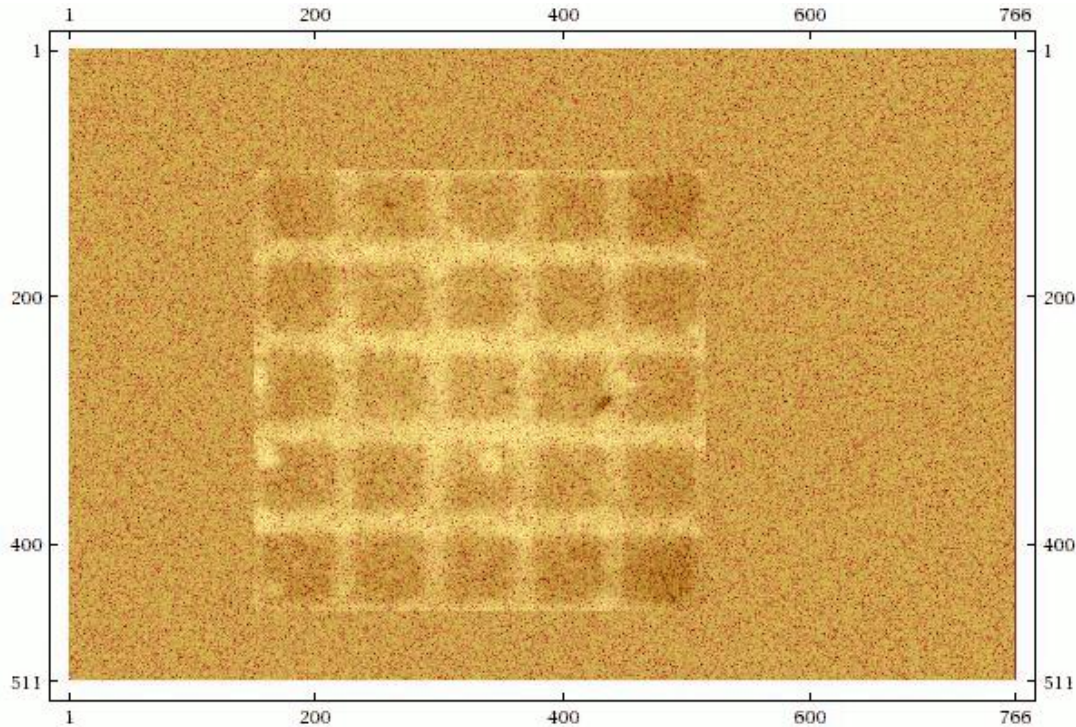


MPPC 33-050-UV-SIRESIN

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Time Resolved imaging of cross-talk

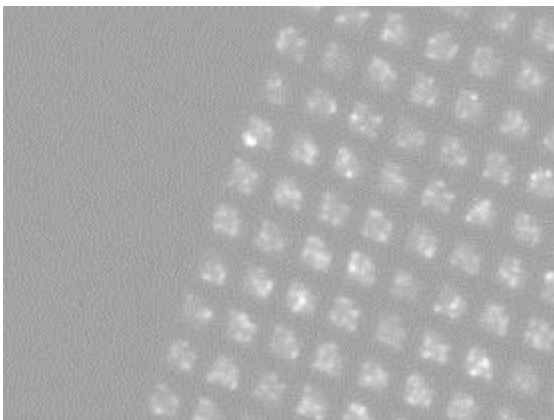
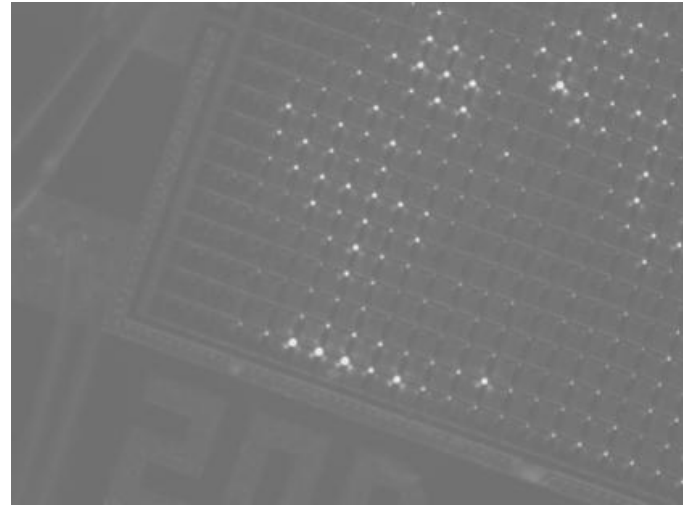
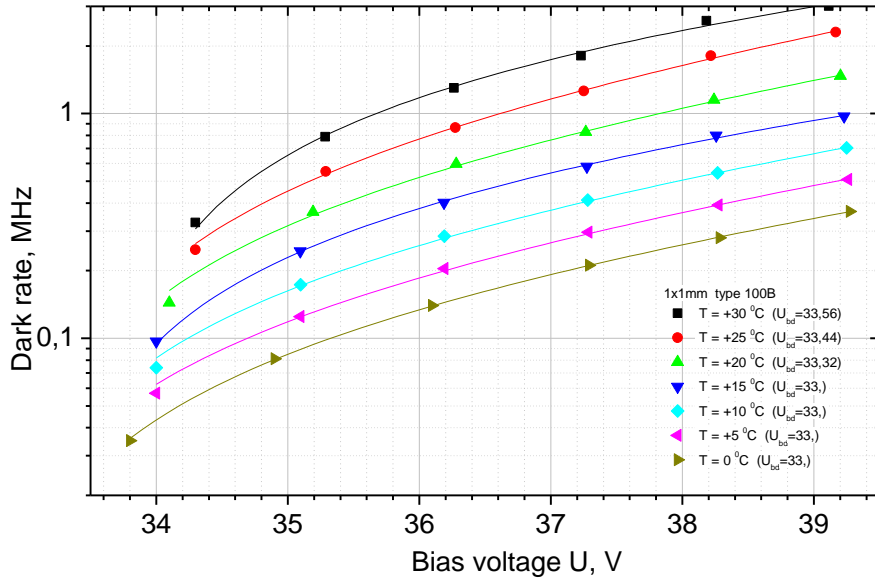


100a – trenches

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SiPM Dark Noise



Frequently technical problems during production of SiPM (sharp edges in the high field region) cause excessive light emission (see above) This heavily contributes into the dark rate, although it is not genuine noise and can be successfully removed in the next production batch.

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and almost no X-talk

Main features

X-talk suppression:

1. Isolating trenches by total internal reflec.

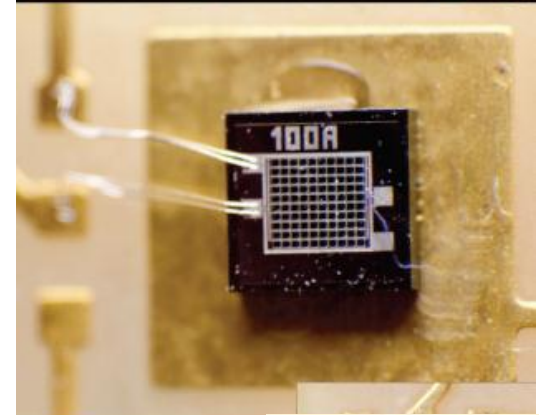
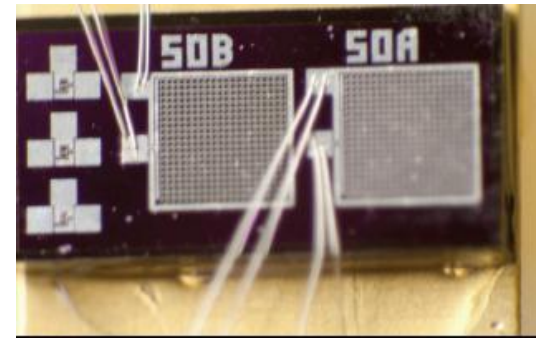
New ways:

2. 2nd p-n junction for isolating the bulk from the active region
3. OC suppression by ion implantation
- 3+. Special absorbing coating

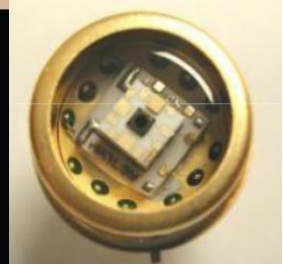
- Thin entrance window, high UV sensitivity

- Very low temperature dependence

- Low noise

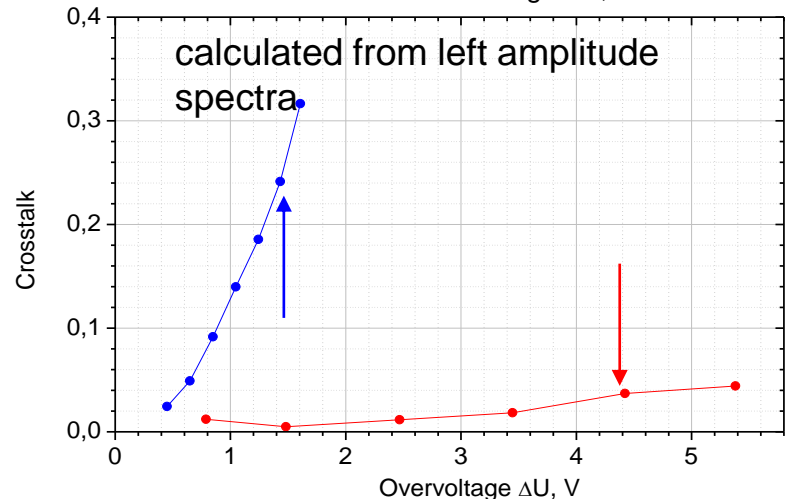
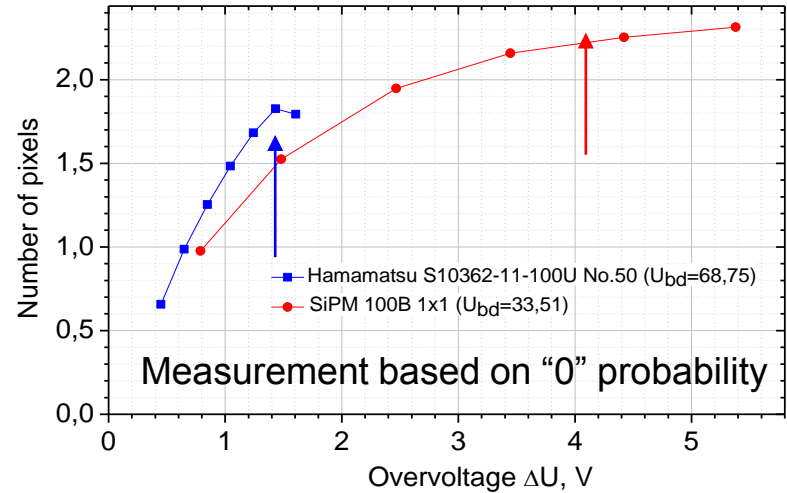
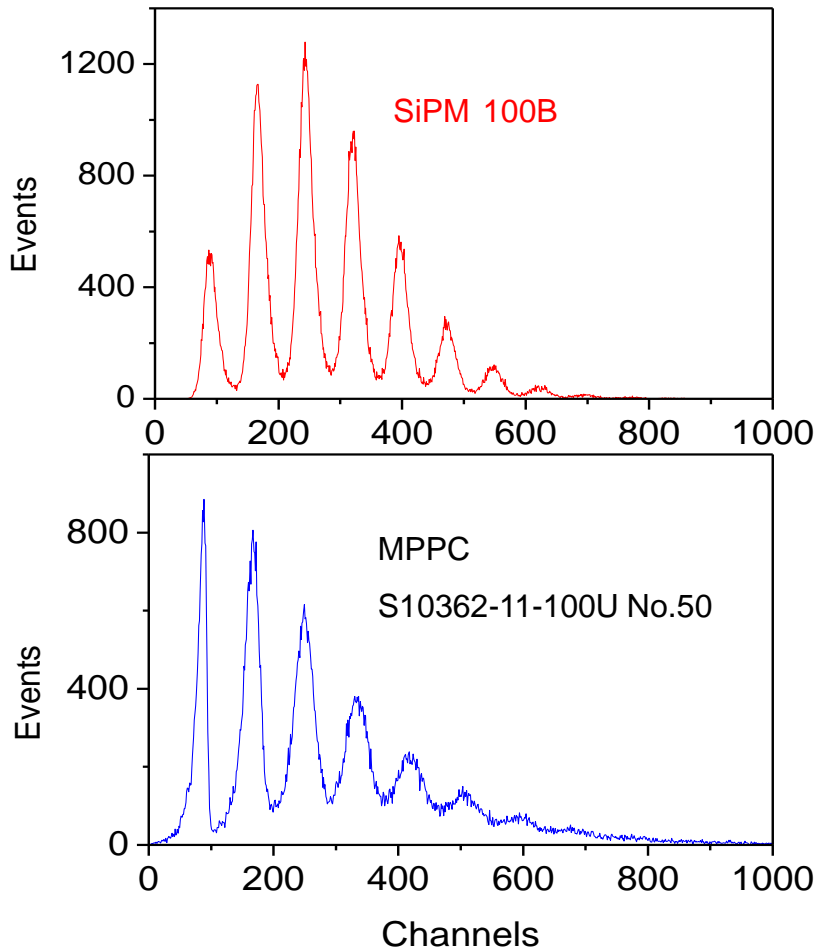


MePhI samples:
Different sizes
1x1mm, 3x3mm,
and breakdown
voltages 24-34V.



SiPM vs. MPPC

SiPM: 1x1 mm², 100x100 μm², Geometrical Efficiency ~80%, T=+25°C, λ = 435 nm
 Same light impinging on both sensors

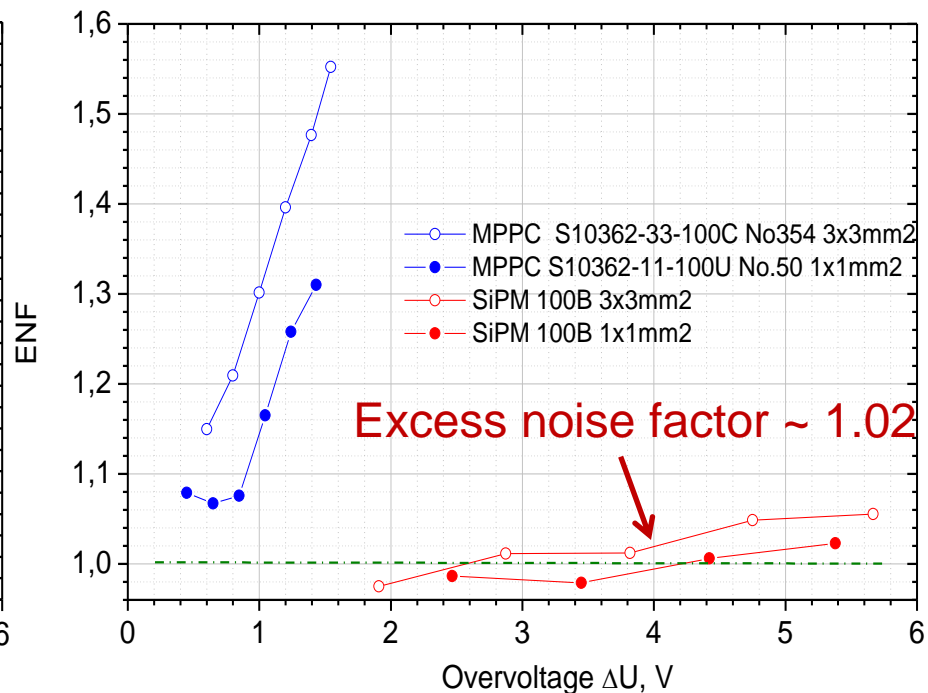
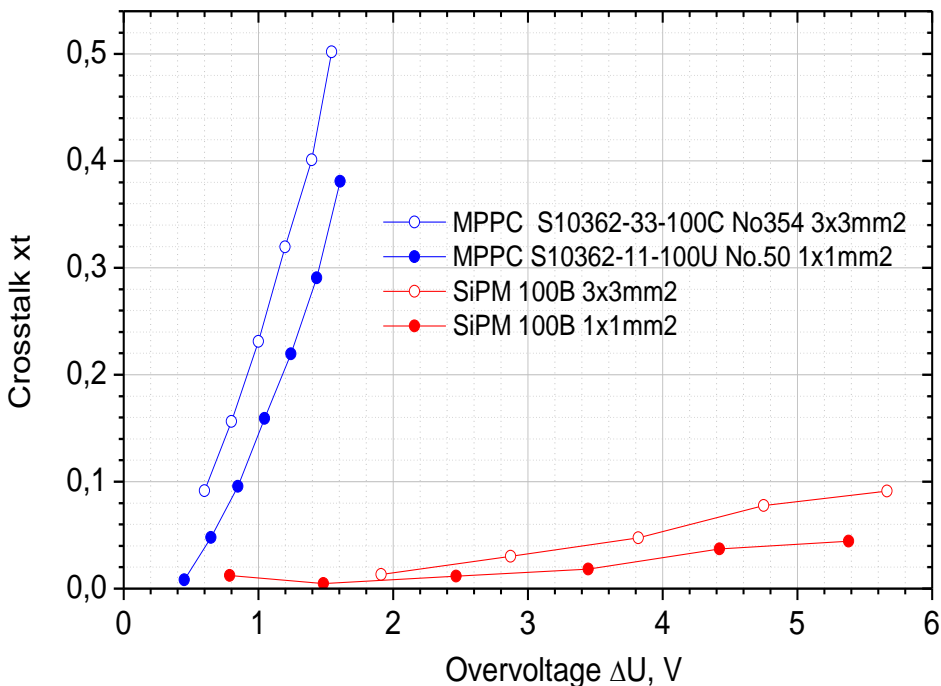


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X-talk and Excess Noise Factor

Light source variation according Poisson law



$$N_{\text{fired_pixels}} = \frac{\langle \text{Mean} \rangle}{A_{1e}} \quad N_{\text{fired_pixels}} = \frac{N_0}{1 - Xt} \quad \left(\frac{\sigma}{\langle \text{Mean} \rangle} \right)_{\text{exp}}^2 = \frac{ENF}{N_0}$$

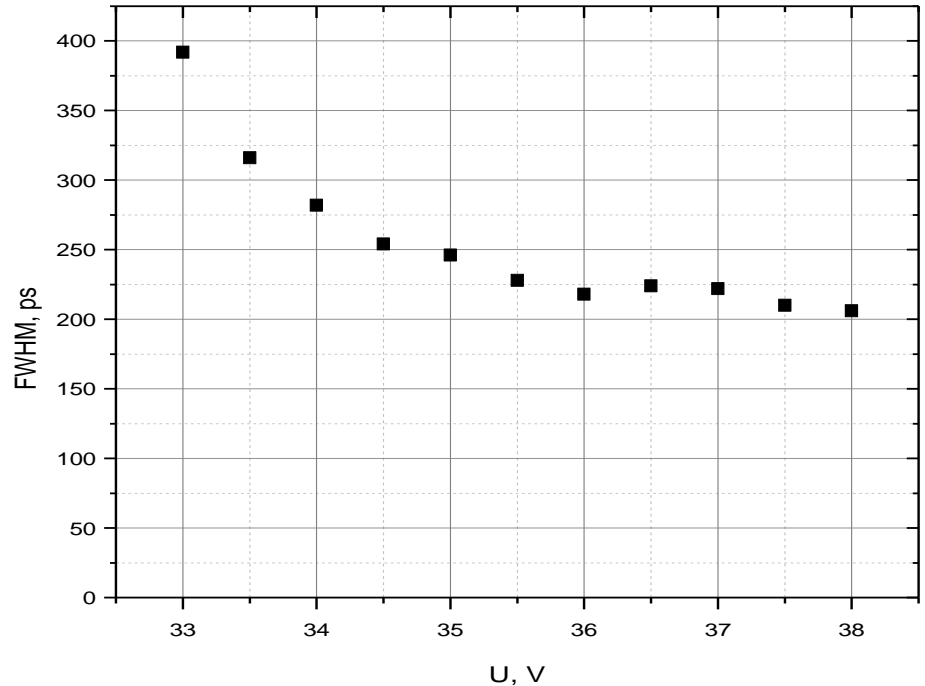
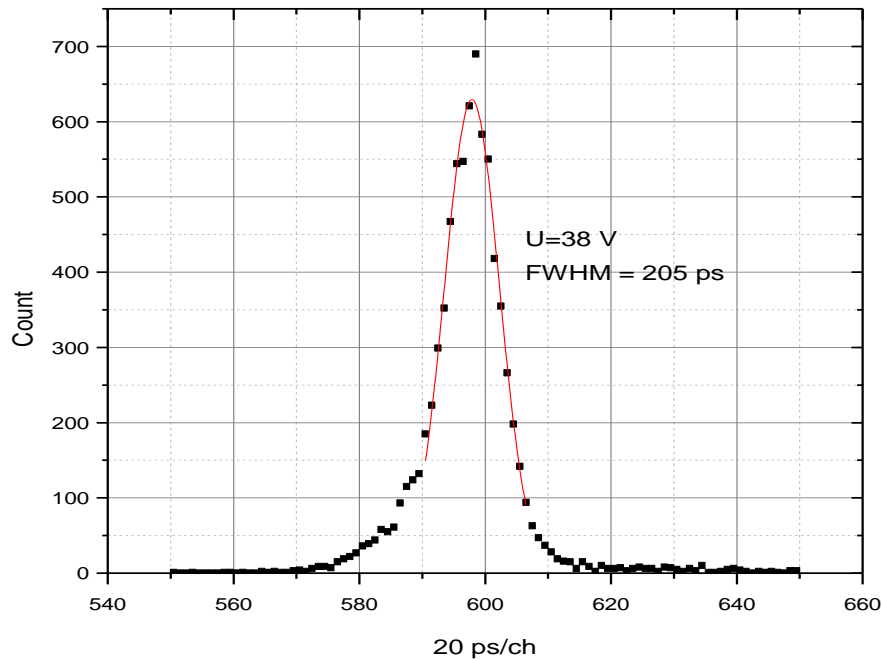
N_0 : number of fired pixels calculated from “0” probability

Xt : crosstalk

A_{1e} : single cell amplitude

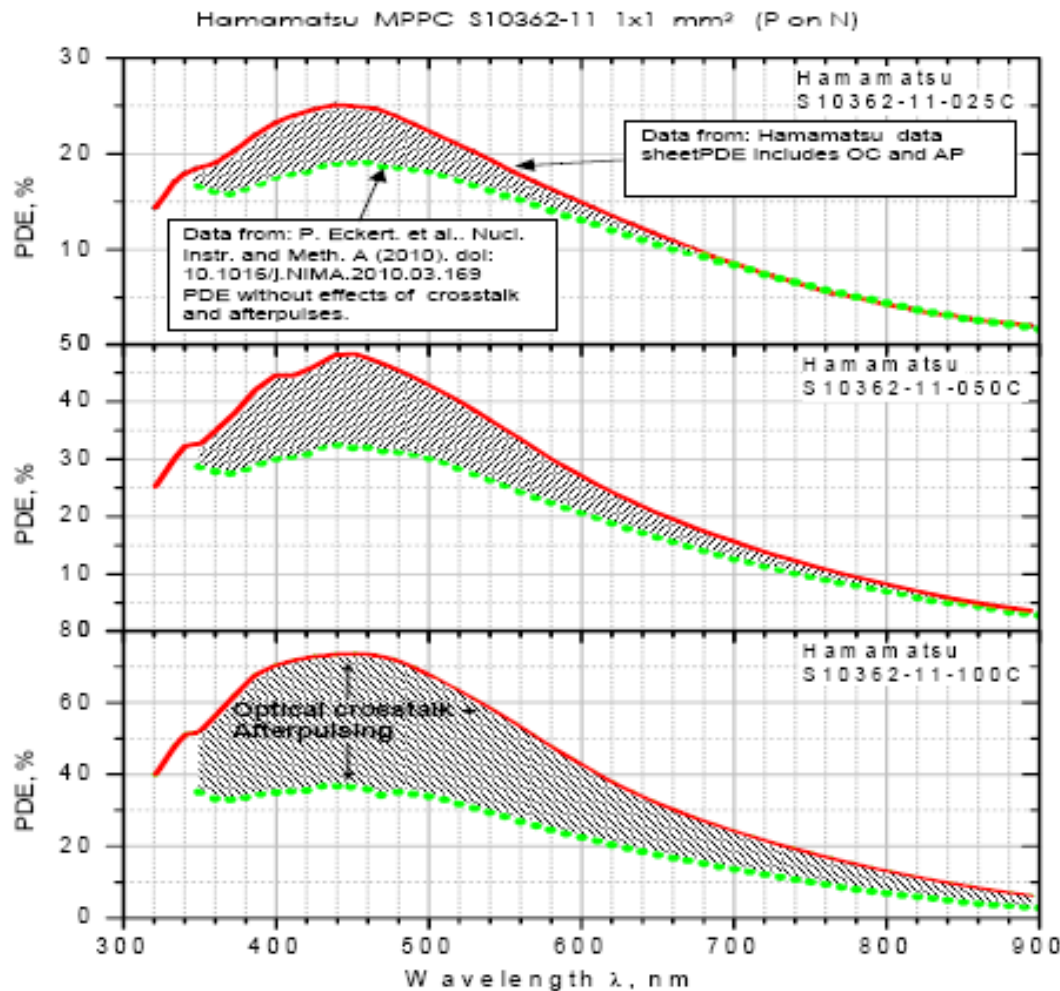
Timing with 3x3mm², type 100B SiPM

40ps laser, 405nm, single photon mode, T= -40°C



Best value measured for 3x3 mm² 100B SiPM is **205 ps**

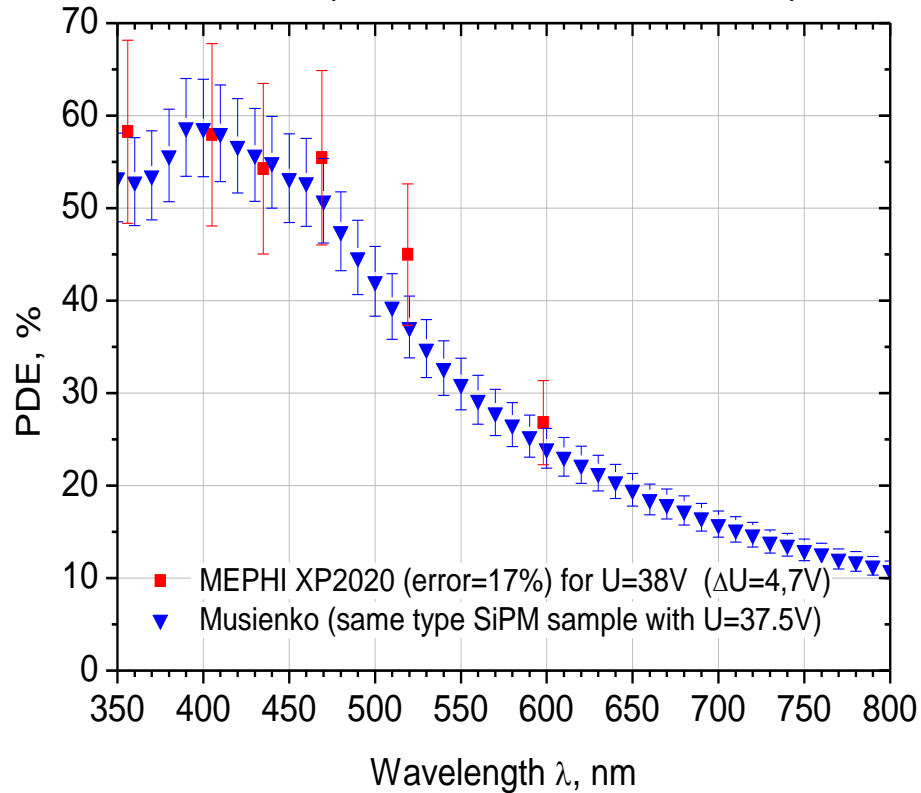
Real and advertised PDE measurements for Hamamatsu MPPCs



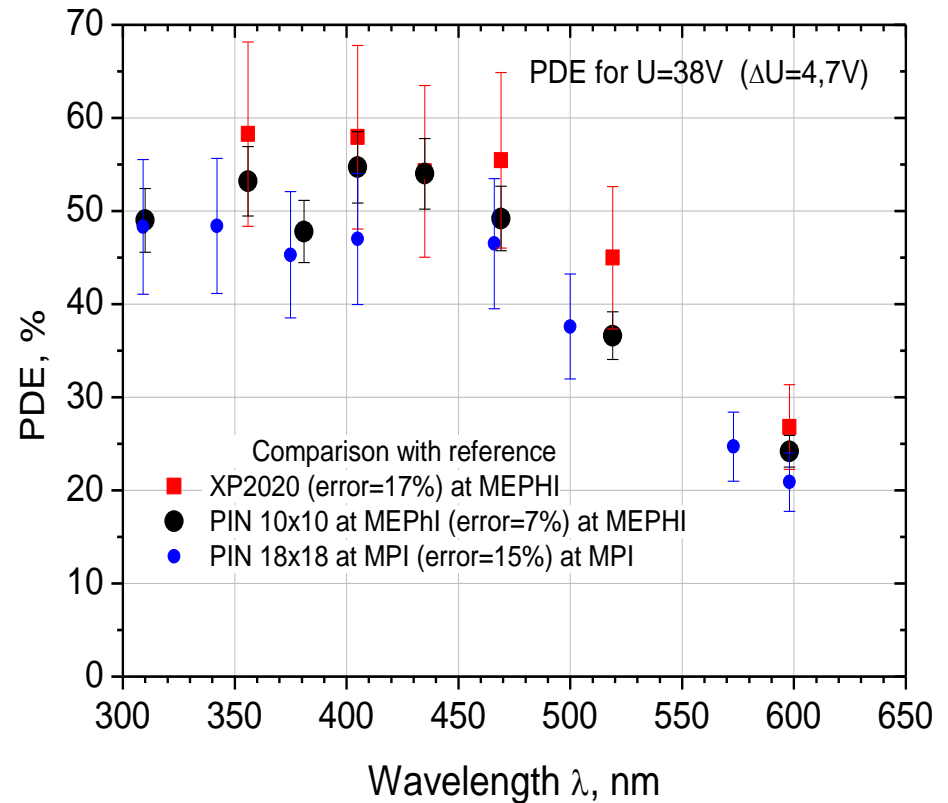
- Until very recently many researchers and companies had serious problems in measuring the real PDE: one needs to disentangle the X-talk and the afterpulsing from genuine efficiency (see left: red line- claimed, green line- in fact measured).
- Thanks to few publications the situation has improved.

Record high PDE (pulsed mode LED, 100B type SiPM, 1x1 mm²)

Measurements at MEPHI and
at CERN (thanks to Y.Musienko)

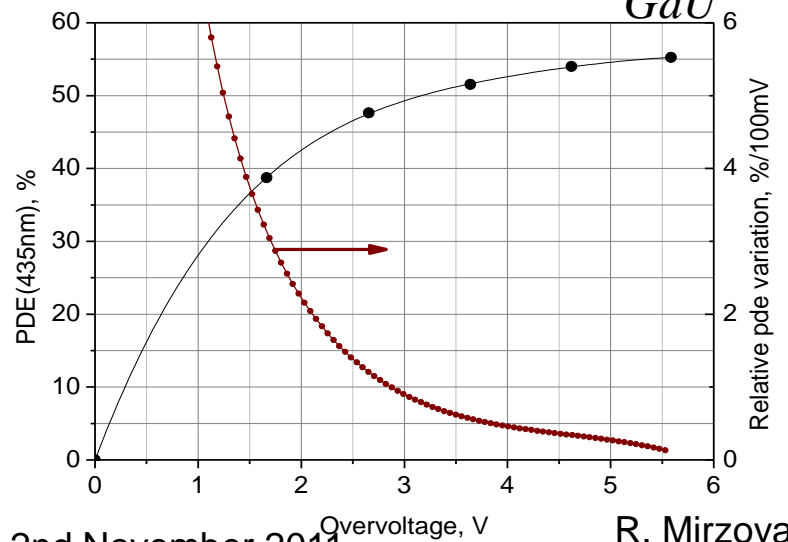
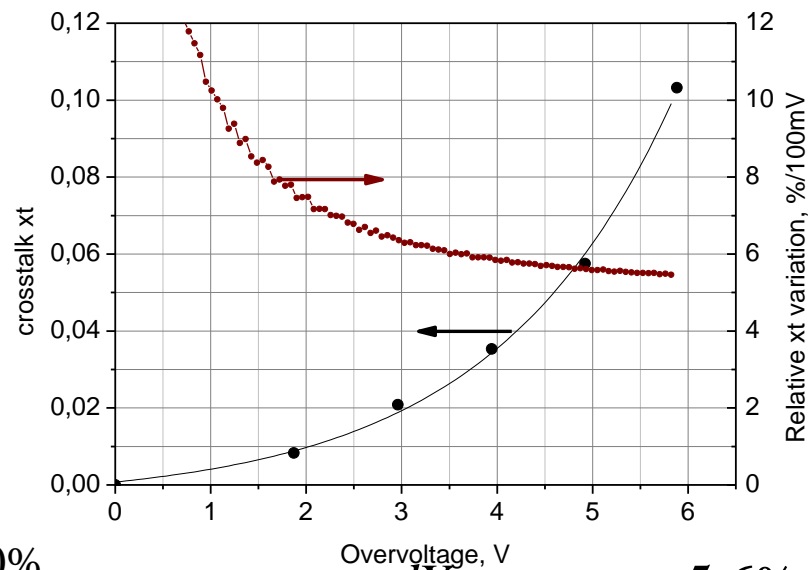
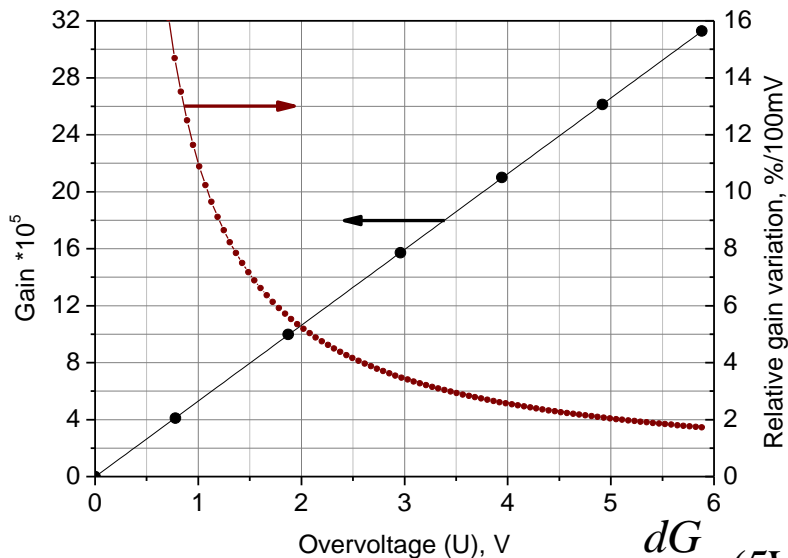


Measurements at MEPHI and at MPI



- The PDE measured with reference calibrated PIN-diodes is slightly lower than with the reference calibrated PMT
- All results are consistent within experimental errors

Voltage stability SiPM 100B for 5V (15%) overvoltage



$$\frac{dG}{GdU} (5V) = \frac{2.0\%}{100mV}$$

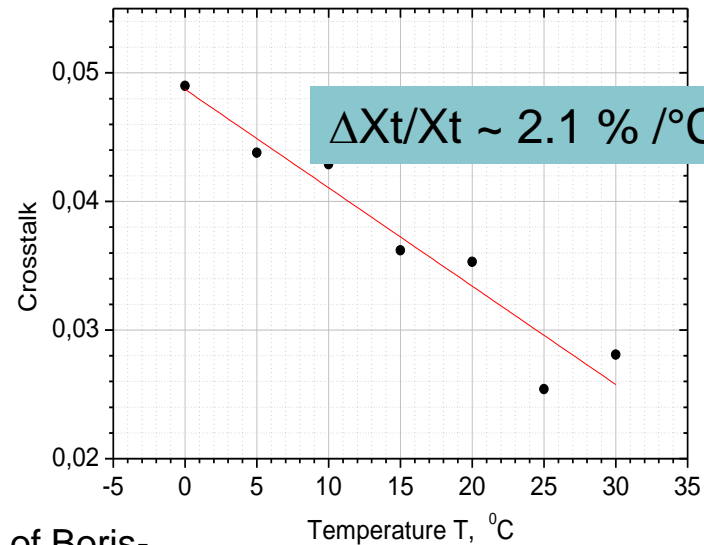
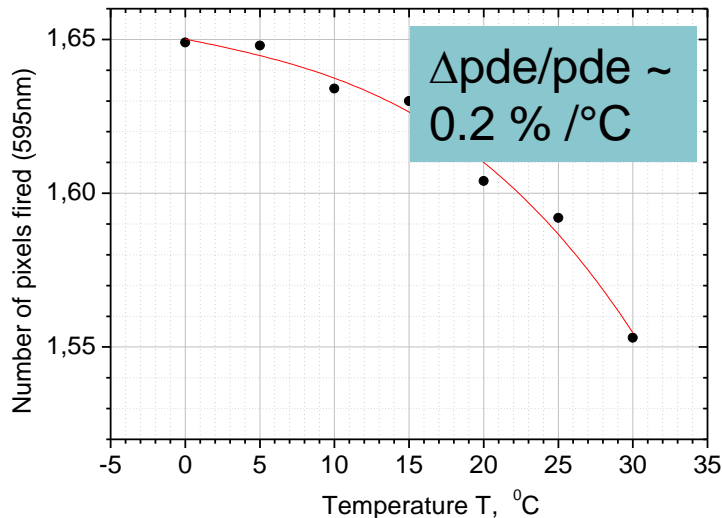
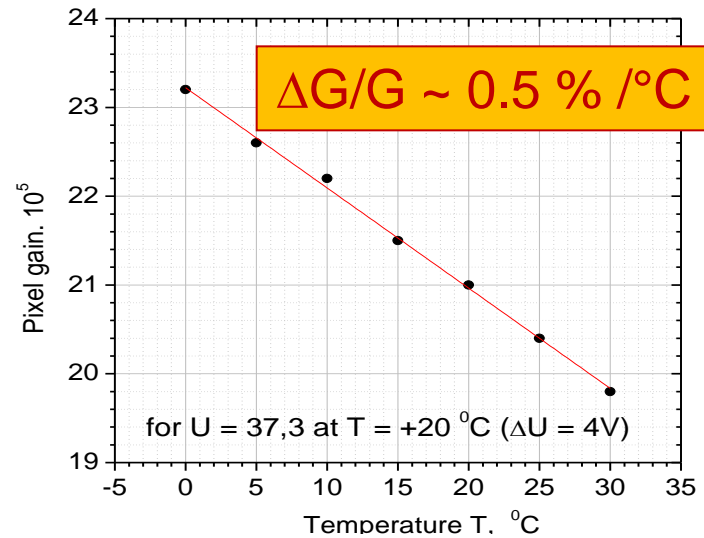
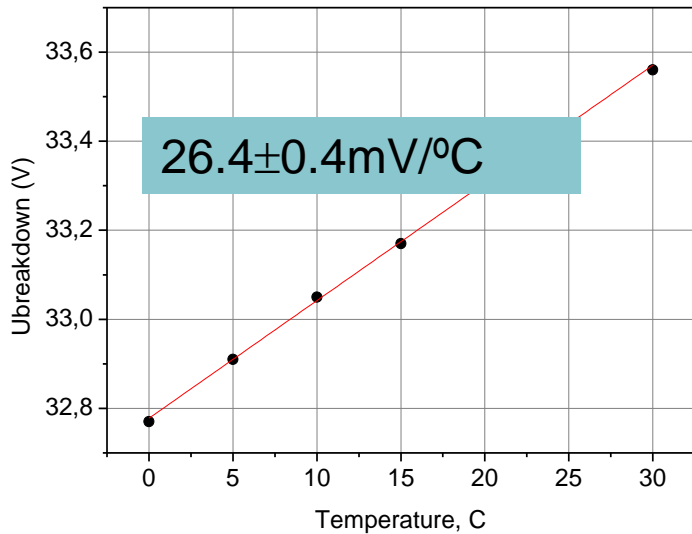
$$\frac{dXt}{XtdU} (5V) = \frac{5.6\%}{100mV}$$

$$\frac{d\varepsilon}{\varepsilon dU} (5V) = \frac{0.25\%}{100mV}$$

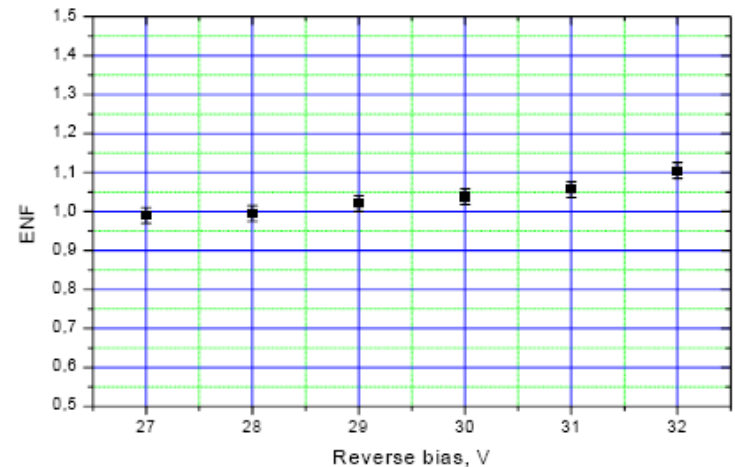
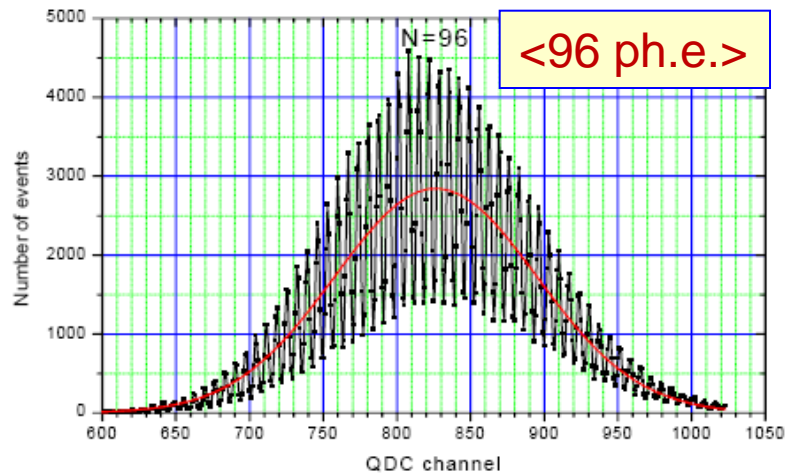
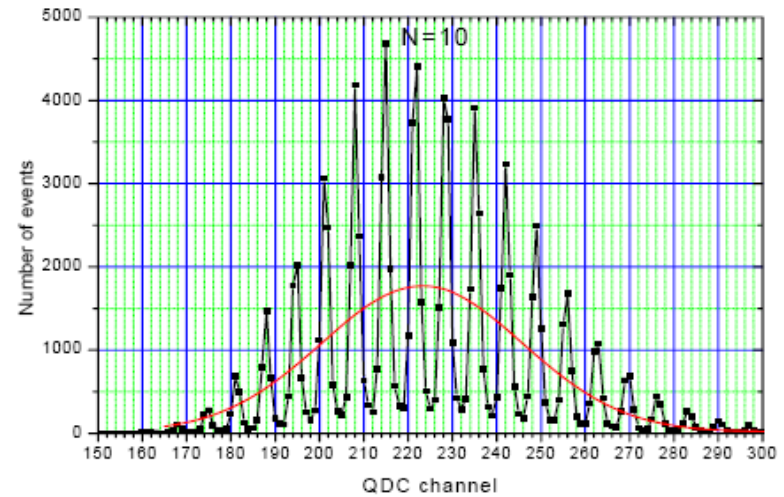
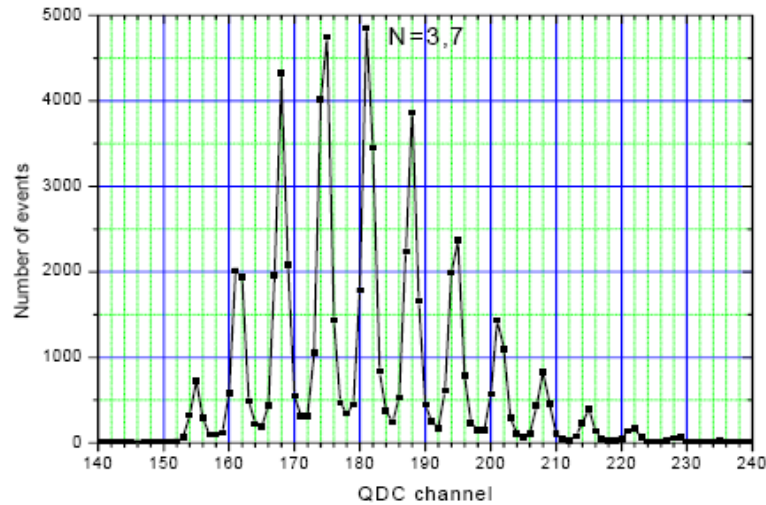
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and almost no X-talk

Temperature dependence type 100B SiPM



SiPM with X-talk suppression: World record of ultra-fast light sensors in amplitude resolution



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and almost no X-talk

We have lost a great scientist, a pioneer in many disciplines, a promoter, a senior friend, a very kind character, a gentleman. He pushed the SiPM to become almost an ideal LLL sensor. This is the beginning of a new revolutionary era for Si sensors.



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Summary

- MEPHI & MPI, with support of Excelitas, have produced SiPMs of 1x1 and 3x3 mm² sizes with extremely high PDE ($\geq 50\%$) in the UV-blue region
- The X-talk is $\sim 3\text{-}5\%$ for saturated PDE ($\Delta U/U \sim 12\text{-}15\%$)
- ENF is ~ 1.02 (due to 4-fold X-talk suppression)
- T° sensitivity: PDE $\sim 0.2\%$ /°C; Gain $\sim 0.5\%$ /°C
- Time jitter (FWHM) (3x3mm²) (100μm pitch) $\sim 200\text{-}300$ ps
- Dark rate $\sim 1\text{MHz}/\text{mm}^2$
- The dream of Boris became true; it's a pity that after so many years and efforts he is not with us to see it
- On the way of becoming commercial product of Excelitas

PET Spectrometry with LYSO and Na²²

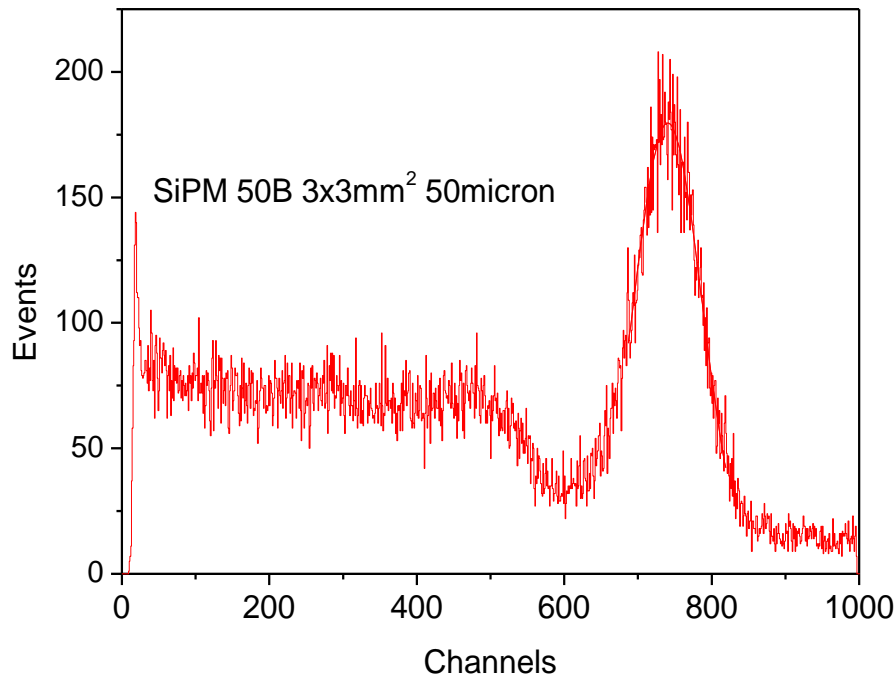
Preliminary. Setup is not yet optimized

Self triggering mode

Amplitude spectra Integration time 1 μ s

LYSO 3x3x5 mm³

Without collimator



Energy Resolution (FWHM) ~14%

